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**DUAL-IMAGING OPTICAL SYSTEM****Abstract of the Disclosure**

An optical imaging system especially for  
5 microlithography includes a first imaging system forming an  
intermediate image of an object, and a second imaging system  
forming, on a surface, an image of the intermediate image.  
A reflective surface directs light from the first imaging  
system to the second imaging system. An aspherical  
10 corrective optical surface is located at or near the  
location of the intermediate image for correcting  
aberrations such as high-order distortion, aberrations due  
to accumulation of manufacturing tolerances, and spherical  
aberration. The first imaging system comprises a positive  
15 power refractive element and a concave mirror. The second  
imaging system comprises refractive elements and no concave  
mirror.